

IN THE CLAIMS:

Please CANCEL claim 9, without prejudice or disclaimer, as this claim was withdrawn from consideration.

Please AMEND claim 1 and ADD new claims as indicated below:

1. (CURRENTLY AMENDED) A substrate assembly for a gas discharge panel, comprising a dielectric layer and a protective layer of MgO being formed in this order on a substrate having electrodes,
wherein the dielectric layer is a laminate of an organic dielectric layer and an inorganic dielectric layer in this order from a side of the substrate,
the inorganic dielectric layer thereby being between the protective layer and the organic dielectric layer.
2. (ORIGINAL) The substrate assembly for a gas discharge panel of claim 1, wherein the organic dielectric layer is made of a material selected from polyimide, polyamide imide, polysiloxane and polysilazane.
3. (ORIGINAL) The substrate assembly for a gas discharge panel of claim 2, wherein the organic dielectric layer is made of a material selected from polysiloxane and polysilazane each having a side chain selected from alkyl, alkoxy and aryl.
4. (ORIGINAL) The substrate assembly for a gas discharge panel of claim 1, wherein the inorganic dielectric layer is made of a material selected from a group consisting of SiO₂, Al₂O₃, TiO₂, ZrO₂, AlN, Si₃N₄ and SiC, and a mixture of two or more thereof.
5. (ORIGINAL) The substrate assembly for a gas discharge panel of claim 1, wherein the inorganic dielectric layer is made of a metal oxide having a smaller bond distance between an oxygen atom and a metal atom than the wavelength of an atom vacuum ultra violet ray.
6. (ORIGINAL) The substrate assembly for a gas discharge panel of claim 1, wherein the organic dielectric layer has a smaller dielectric constant than that of the inorganic dielectric layer.

7. (ORIGINAL) The substrate assembly of claim 1, wherein the organic dielectric layer has a thickness of 5-20 μm and the inorganic dielectric layer has a thickness of 0.5-2 μm .

8. (ORIGINAL) The substrate assembly of claim 1, wherein the protective layer has a thickness of 0.5-1.5 μm .

9. (CANCELED)

10. (ORIGINAL) A gas discharge panel, comprising:
a substrate assembly as disclosed in claim 1 disposed on a front side of the panel as a front substrate assembly;
a rear substrate assembly facing the front substrate assembly; and
a discharge space formed between the front and rear substrate assemblies,
wherein the rear substrate assembly is provided with barrier ribs for defining the discharge space and phosphors, the barrier ribs being formed on a substrate having electrodes, the phosphors being formed on side walls of the barrier ribs and on the substrate defined by the barrier ribs.

11. (NEW) A substrate assembly for a gas discharge panel, comprising:
an organic dielectric layer formed on a substrate having electrodes;
an inorganic dielectric layer formed on the organic dielectric layer, where the organic dielectric layer and the inorganic dielectric layer are formed together as a laminate; and
a protective layer of MgO formed on the inorganic dielectric layer,
the inorganic dielectric layer thereby being between the protective layer and the organic dielectric layer.

12. (NEW) The substrate assembly for a gas discharge panel of claim 11, wherein the organic dielectric layer is made of a material selected from polyimide, polyamide imide, polysiloxane and polysilazane.

13. (NEW) The substrate assembly for a gas discharge panel of claim 12, wherein the organic dielectric layer is made of a material selected from polysiloxane and polysilazane each having a side chain selected from alkyl, alkoxy and aryl.

14. (NEW) The substrate assembly for a gas discharge panel of claim 11, wherein the inorganic dielectric layer is made of a material selected from a group consisting of SiO_2 , Al_2O_3 , TiO_2 , ZrO_2 , AlN , Si_3N_4 and SiC , and a mixture of two or more thereof.

15. (NEW) The substrate assembly for a gas discharge panel of claim 11, wherein the inorganic dielectric layer is made of a metal oxide having a smaller bond distance between an oxygen atom and a metal atom than the wavelength of an atom vacuum ultra violet ray.

16. (NEW) The substrate assembly for a gas discharge panel of claim 11, wherein the organic dielectric layer has a smaller dielectric constant than that of the inorganic dielectric layer.

17. (NEW) The substrate assembly of claim 11, wherein the organic dielectric layer has a thickness of 5-20 μm and the inorganic dielectric layer has a thickness of 0.5-2 μm .

18. (NEW) The substrate assembly of claim 11, wherein the protective layer has a thickness of 0.5-1.5 μm .

19. (NEW) A gas discharge panel, comprising:
a substrate assembly as disclosed in claim 11 disposed on a front side of the panel as a front substrate assembly;
a rear substrate assembly facing the front substrate assembly; and
a discharge space formed between the front and rear substrate assemblies.